

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	204	(wafer or substrate) same (stage or table or support\$3) same (discharg\$3 or exhaust\$3 or expell\$3 or remov\$3) near6 gas near5 liquid	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:23
L4	8594	(immers\$3 near4 (expos\$3 or lithograph\$2) or (water or immers\$3 or liquid) near5 (lens or projection near2 system) near5 (wafer or substrate))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:22
L5	19	3 and 4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:11
L6	2	wo-9949504-\$.did. or wo-99049504-\$.did.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:20
L7	9340	355/53,67,72,75.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:21
L8	14	3 and 7	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:21
L9	757	(immers\$3 near4 (expos\$3 or lithograph\$2) or (water or immers\$3 or liquid) near5 (lens or projection near2 system) near5 (wafer or substrate)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:22
L10	15	(wafer or substrate) same (stage or table or support\$3) same (discharg\$3 or exhaust\$3 or expell\$3 or remov\$3) near6 gas near5 liquid.clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:23
L11	622	(density or concentration) near5 (burls or dimples or projections or protrusions or protuberances).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:24

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L12	100572	(chuck\$3 or hold\$3 or support\$3 or burl near2 plate) same (projections or protuberances or protrusions or burls or pins).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:25
L13	1	9 and 11 and 12	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:26
L14	6	9 and 10	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/23 10:27